

Company Profile

VIA electronic GmbH

„The Smart LTCC Foundry“

Robert-Friese-Strasse 3

D-07629 Hermsdorf, Germany

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www.via-electronic.de

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VIA electronic

Company Profile

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Company Profile

Company Informations

**VIA electronic GmbH is located in
Hermsdorf/Germany**

**Embedded in a network of SMEs and
Research Institutes**

Reputed as a „SMART LTCC Foundry“

**Specialised in the realisation of innovative
solutions in LTCC Technology.**

**On the market since 1997 with 18 Employees
per today**

Certified according to ISO 9001:2000



Company Profile

Background

VIA electronic is a Management buy out of the LTCC activity from Siegert electronic in Nürnberg

The founder gained reputation in Thickfilm hybrids and LTCC from 1987 bis 1997 in Siegert electronic /Nürnberg

In October 1997 VIA electronic was founded in the Industry Park Tridelta in Hermsdorf/Thuringia

Core competence: customer taylored solutions in innovative LTCC multilayer ceramics from the development stage until series production

Products: Mulilayer substrates, Multichip Modules, 3-D Packages, Multilayer components



Company Profile

Background: Historical Bricks

Region: Hermsdorf is a center for Technical Ceramics since 1910.

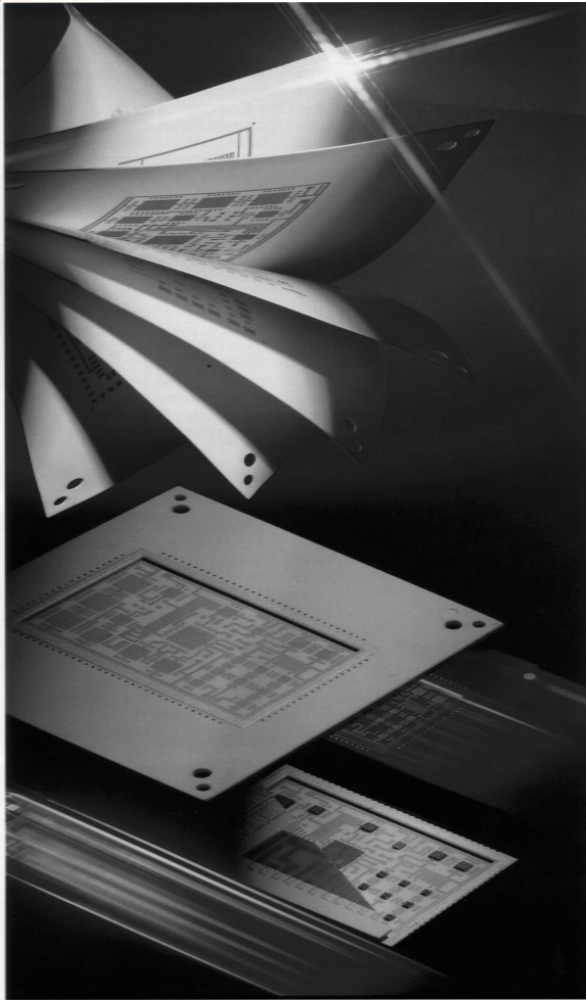
Up to 1989 The „Ceramic Plants“ of Hermsdorf were a 7.000 people company

Company: VIA electronic was found in Hermsdorf in 1997 as a management buy out from Siegert electronic, a German Hybrid manufacturer dealing with LTCC since 1986



Company Profile

LTCC Technology



Unsintered ceramic foils (ceramic) are mechanical shaped

Vertical conductive paths (Vias) are punched as very small holes and filled with metal paste afterwards.

The lateral conductive pattern is screenprinted in advanced thickfilm technology

The separate layers are positioned accurately and laminated together by hot pressing.

This laminate is sintered in a singulare process (cofiring) at low temperatures (low temperature) at about 900°C to the completely wired substrate or package.



Company Profile

Services

- **State of the art CAD design and layout**
- **Flexible manufacturing line**
- **All lot sizes**
- **Installed capacity of 5 Mn circuits per year**
- **High precision processing**
- **Experienced in different material systems**



Company Profile

Products

- RF modules
- 3D packages
- Multichip modules
- Multilayer ceramic boards
- Multilayer components
- Thinfilm substrates



Company Profile

Capital Structure

Stock capital

410.000 €

Shareholders

43,5 %

Franz Bechtold

37,5 %

Microtel s.p.a.

19,0%

Siegert TFT



Company Profile

Development

	Employees	Turnover K€
1997	Foundation in October	
1998	7	300
2001	15	1000
2004	14	1.000
2006	16	1.150
2008	18	1.250



Company Profile

Milestones

1997	Foundation
1999	Cleanroom Operation 150m ²
2000	Completion of the Investments First business year without losses
2002	Certification ISO 9001:2000 Expansion manufacturing room 150m ²
2003	Set up of a European Sales Network
2005	Expansion Laboratory room 250m ²
2007	Participation of 25% in VIA optronics



Company Profile

Customers

Siegert electronic
Siemens
Askion
Ketek

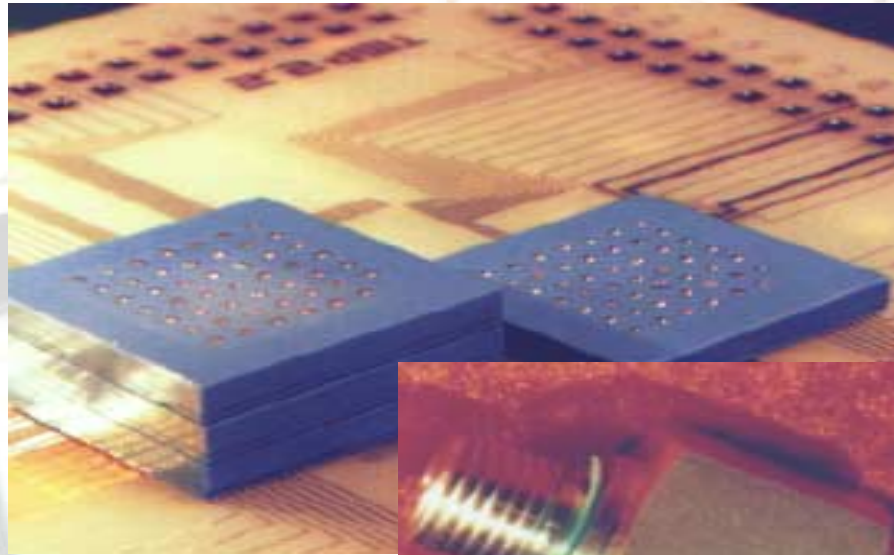
Ericsson
EADS
CEA-Leti
Thales



Company Profile

Markets and Marketshares

- Telecom: 40%
- Medical: 20%
- Industry: 20%
- Avionic: 10%
- Automotive: 10%



Company Profile

Quality Management

DIN ISO 9000:2000 certified since 2002

Thüringen Quality Award 2003



Company Profile

Arguments for LTCC

Highest Integration Capability

< 150 μm lines and spaces

< 150 μm via diameter

integrated passive components: resistors, capacitors, inductors, filters

integrated fluidic components: channels, chambers

Cavities and windows for active components

Integrated sensor components

Integrated heater



Company Profile

Arguments for LTCC

- **Superior Reliability**

- Life Time of more then 50 Years
- Operating Temperature up to 250°C
- Temperature Cycling Stability from -55 to 150 °C



Company Profile

Innovation Capability for LTCC

The nanotechnology approach

Gradient material properties

Surface properties

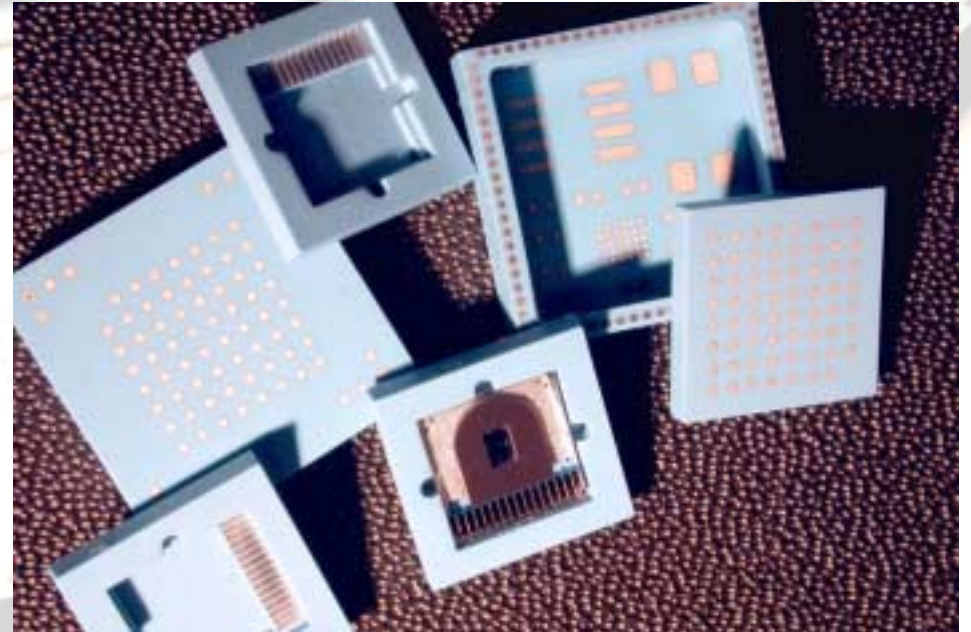
Mechanical properties



Company Profile

Innovation Capability for LTCC

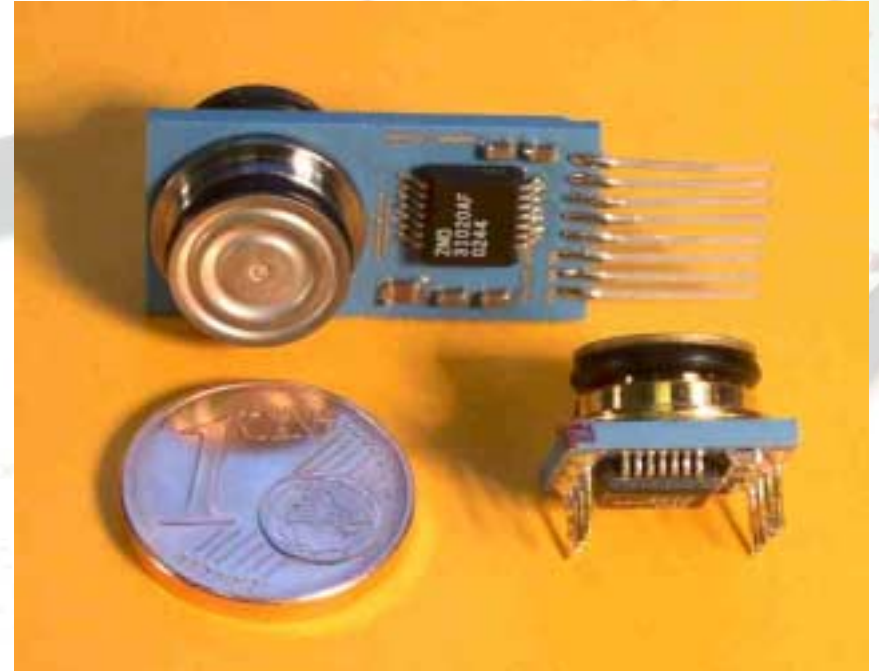
- **High innovation force**
 - High temperature electronics
 - Sensors
 - Microsystems
 - Optoelectrical systems



Company Profile

Innovation Capability for LTCC

- **High innovation speed**
 - Material development
 - Process integration
 - Component integration
 - Hybrid microsystem integration



Company Profile

R&D: Smart LTCC Components with integrated passives

L/C Bandpass



Power transformer



Ferritic Itcc inductor



SMT compatible LTCC Integrated Passive components for low power, high power, low frequency and high frequency applications using new dielectric materials and new manufacturing processes

LC phase shifter



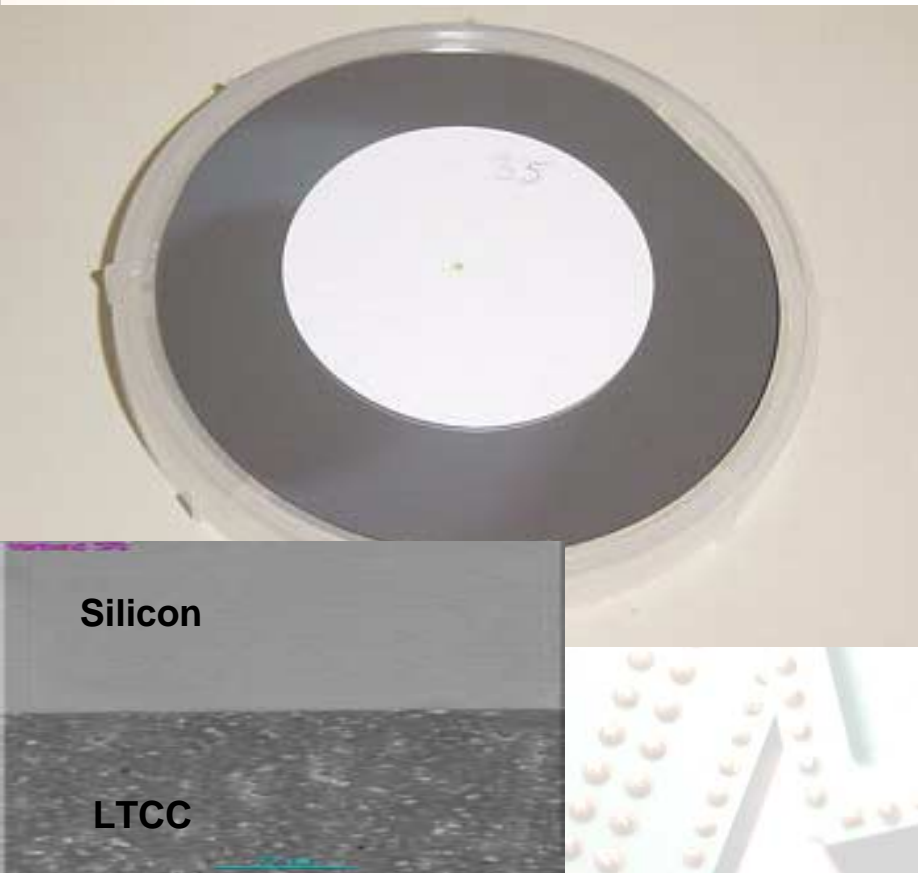
Integrated resistor



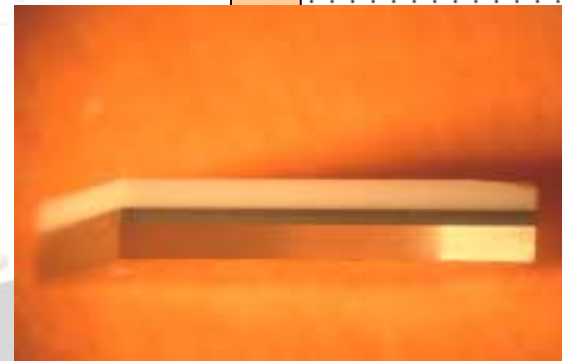
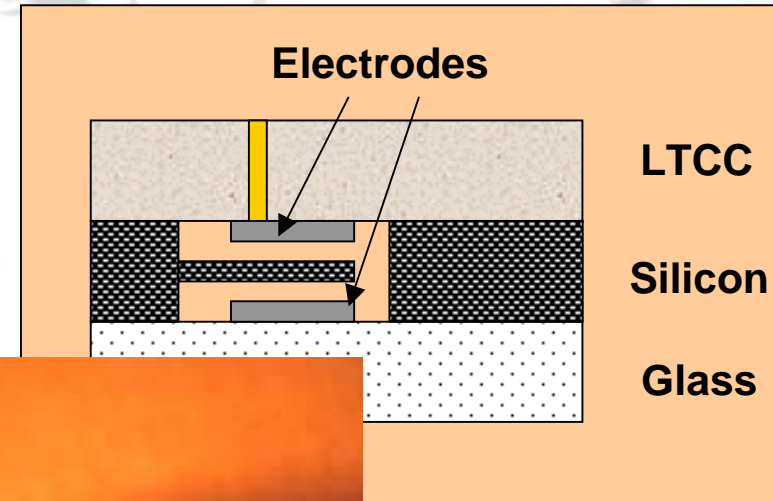
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R&D : Wafer Level Packaging by anodic bonding to LTCC

LTCC substrate bonded with Si- wafer
and cross section of bonded area

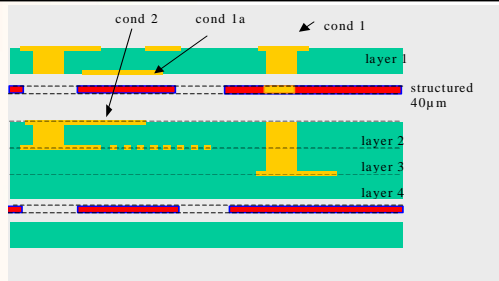


LTCC metallized wafer bonded with the
Si- and glass-wafer simultaneously by
anodic bonding at 400°C, 1500 V,
Schematic and Demonstrator

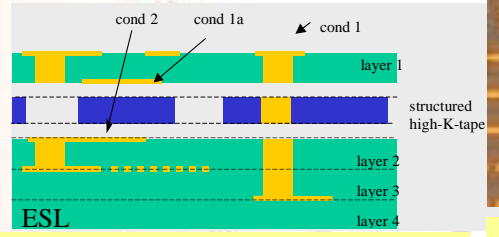


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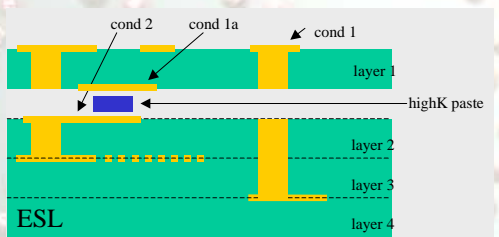
R&D: Integrated Passives for MEMS switch modules



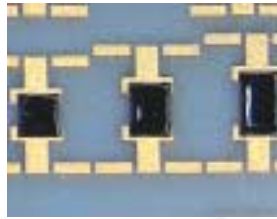
951C2/ 37µ layer



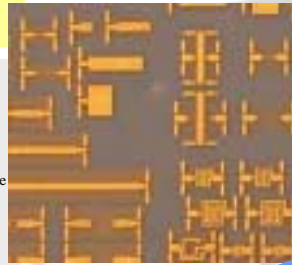
Integrated high-k-tape



Integrated high-k ink



resistors

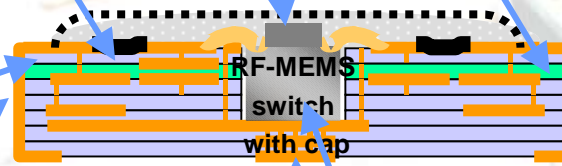


RF-structures

sealing

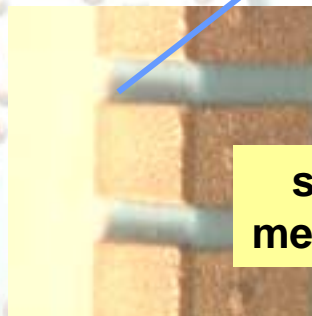


high k layer



RF-MEMS switch with cap

thermal vias / spreader



sidewall metallization



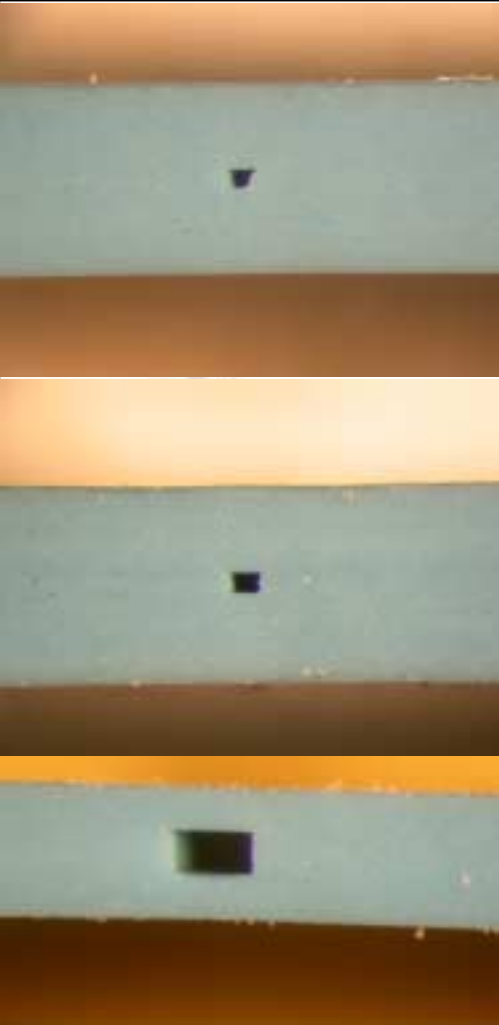
cavities for RF-MEMS



Source: Daimler Chrysler Research

Company Profile

R&D: Integrated Fluidics



Fluidic channel

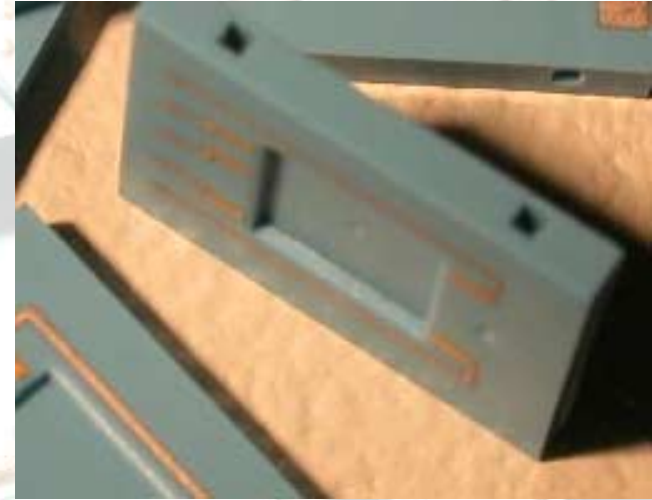
0,1 x 0,1 mm

Fluidic channel

0,2 x 0,2 mm

Fluidic channel

0,4 x 0,6 mm



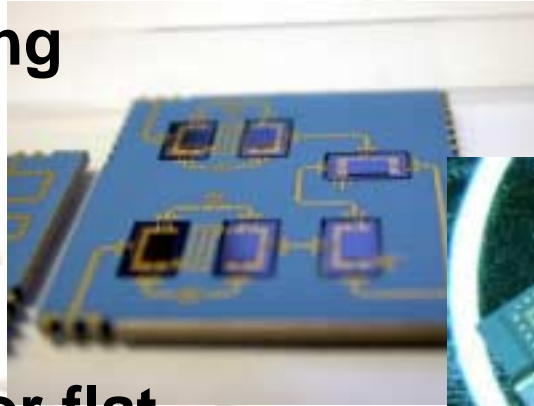
Sensorpackage
with integrated
Fluidic



Company Profile

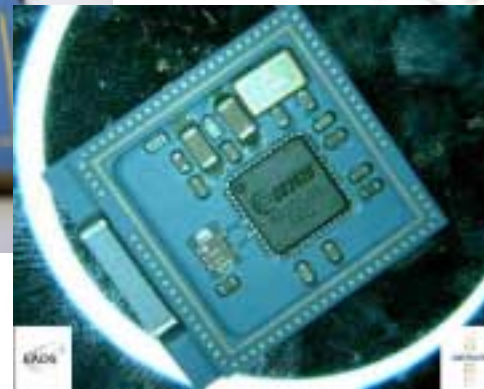
Innovativ Processes and Materials

**Si Matched LTCC
and anodic bonding
at wafer lever**



**AuSn brazing of
Ring frames and
heat sinks**

**Ferritic LTCC for flat
inductors and
transformers**



**Fine pitch
Technology for
high frequencies**

**High performance
LTCC for the
Integration optical
components**

**Direct bonded
thin film on LTCC**



Company Profile

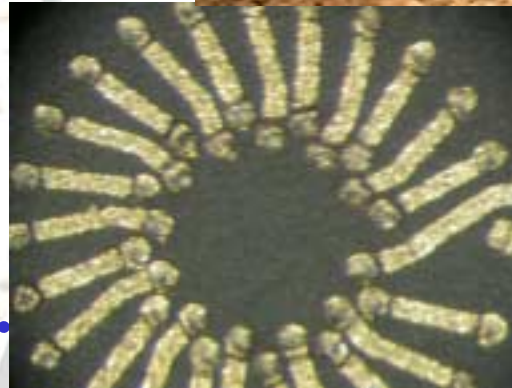
Innovativ Processes and Materials

**Integrated
Microreactors**



**0- Shrink
Technology wiht
highest precision**

**Integrated Sensors in
thickfilm and thinfilm
technology**



**Integrated
microembossing
technology for high
power**

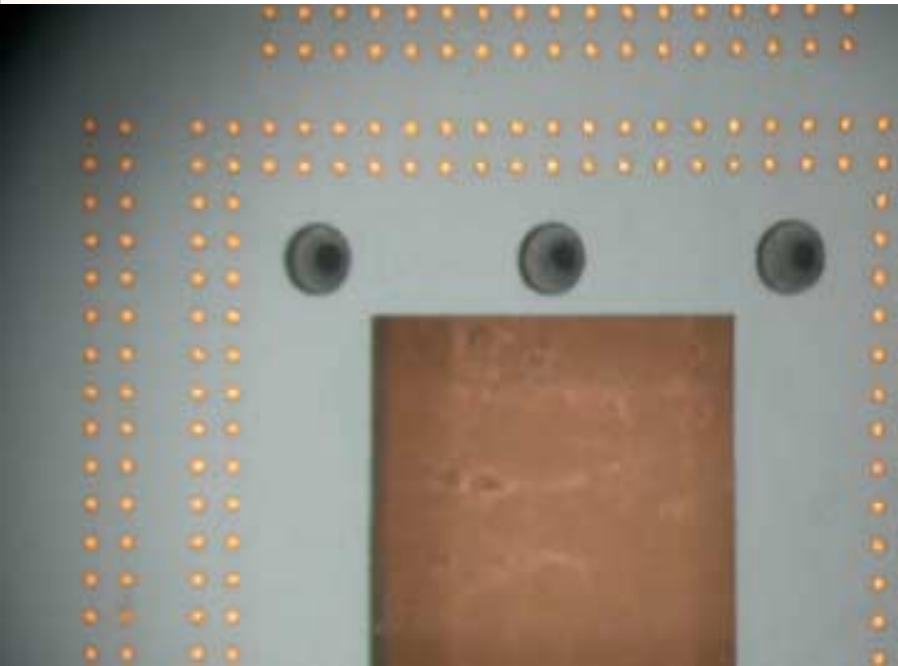
**Monolithic integrated
R-C-L components**



Company Profile

Advanced applications : Integrated Optoelectronics

Pressure assisted sintering



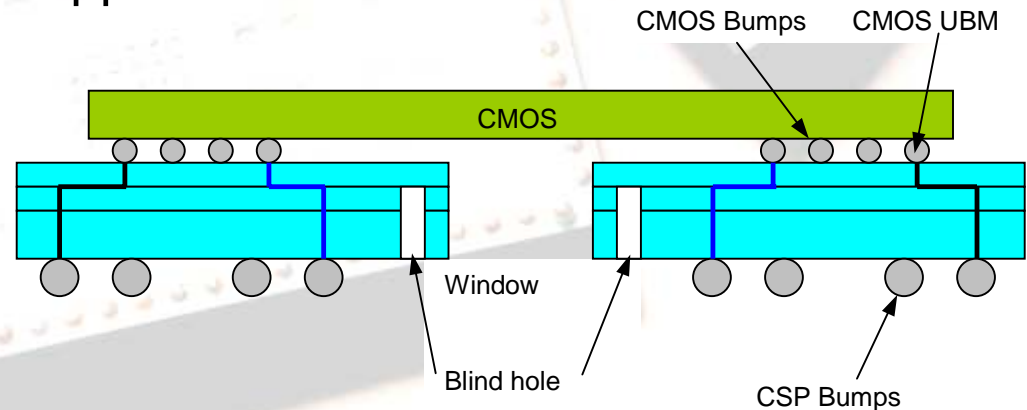
Material DuPont 951

Cavities, postfire laser cut

Blind holes, postfire laser drilled $\pm 25\mu$

Vias 90 μ m, position $\pm 50\mu$ m

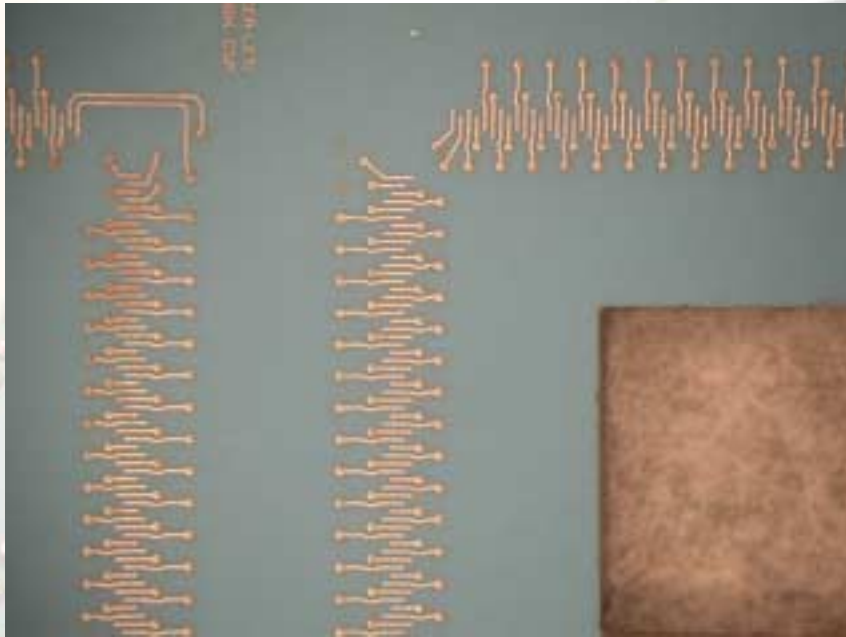
Application: CSP for Si optical bench



Company Profile

Advanced Applications : Integrated Optoelectronics

Pressure assisted sintering



Lapped
 $ra < 0,2\mu m$

Thickness 1,5mm +/- 5 μm

Vias Interconnection: Thinfilm

Interconnect: BGA Backside

Operating speed up 10Gbit

Company Profile

Advanced applications: Automotive

- Connection Electronic-Mechanics
- 25 Interconnections per cm^2
- Thermal Conductivity through thermal Vias
- Operating Temperature up to $125\text{ }^\circ\text{C}$



Company Profile

Advanced Applications : Biotechnology and Biosensors



Fluidic Chip with integrated high voltage conductors

Fluidic interconnection at 100 μ m channel



Company Profile

Advanced applications: Optoelectronics



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Company Profile

Cooperation: Full R&D Chain from materials to products

From ceramic powders to ceramic based Microsystems and devices



Dedicated to Grow:

A local Network of Industries, R&D Institutes and Universities, for the Development and Realisation of Ceramic Based Microelectronic Devices and Microsystems



Company Profile

VIA Network



Company Profile

other regular activities

Exhibitions: SMT in Nürnberg, Micronora in Besancon

Memberships: ZVEI, Imaps Germany, MTT Thüringen, Eurimus

Research cooperations: 6th FP, Eureka, BMBF R&D Programms

Partnerships: Microtel S.p.a. Milano, Siegert TFT Hermsdorf



Company Profile

news

Streamlining of the shareholder structure

Expansion of the manufacturing capabilities

Hermetic Packages

